

<b>Notice of References Cited</b>	Application/Control No. 10/601,409		Applicant(s)/Patent Under Reexamination JOHNS ET AL.	
	Examiner Adam R. Giesy		Art Unit 2651	Page 1 of 1

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	U	Shi, Xiaolei; Thornton, Robert L.; and Hesselink, Lambertus. A Nano-aperture with 1000x Power Throughput Enhancement for Very Small Aperture Laser System (VSAL). Proceedings of SPIE. Volume 4342. January 2002. pp. 320-327.			
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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